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Attorney Docket: 081468-0306369  
Client Reference: P-1790.000-US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of:  
**JOOST JEROEN OTTENS , ET AL.**

Confirmation Number: 4455

Application No.: 10/743,272

Group Art Unit: 1756

Filed: December 23, 2003

Examiner: Christopher G. Young

Title: OPTIMIZED CORRECTION OF WAFER THERMAL DEFORMATIONS IN A LITHOGRAPHIC PROCESS

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated October 12, 2006, Applicant elects, without traverse, for examination: Group I, encompassing claims 1-34, drawn to methods of correcting thermally induced field deformations.

Applicant reserves the right to file a divisional application for non-elected claims at a future date, if necessary.

Respectfully submitted,

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